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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/751,390	01/05/2004	Johannes Kaeppeler	03345-P0046A	2672
	7590 06/05/200 EWARD IOHNSTON	Johannes Kaeppeler 03345-P0  REENS, LLC  ART U  176	EXAMINER	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
		10/751,390	KAEPPELER, JOHANNES			
	Office Action Summary	Examiner	Art Unit			
		Sylvia R. MacArthur	1763			
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with the	correspondence address			
WHIC - Exte after - If NC - Failt Any	CORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Diperiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing led patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION  36(a). In no event, however, may a reply be will apply and will expire SIX (6) MONTHS from the application to become ABANDON	ON. timely filed om the mailing date of this communication. NED (35 U.S.C. § 133).			
Status						
1)⊠	Responsive to communication(s) filed on 26 M	<u>arch 2007</u> .				
2a)⊠	This action is <b>FINAL</b> . 2b) This action is non-final.					
3)[	Since this application is in condition for allowar	•				
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11,	453 O.G. 213.			
Disposit	ion of Claims	•				
4)⊠	Claim(s) 1 and 3-19 is/are pending in the applie	cation.				
	4a) Of the above claim(s) is/are withdraw	vn from consideration.				
5)□	Claim(s) is/are allowed.					
	Claim(s) 1 and 3-19 is/are rejected.					
·	Claim(s) is/are objected to.	•	•			
. 8)∐	Claim(s) are subject to restriction and/or	r election requirement.				
Applicat	ion Papers					
9)[	The specification is objected to by the Examine	r.				
10)🖂	The drawing(s) filed on 05 January 2004 is/are:	a)⊠ accepted or b)☐ objecte	ed to by the Examiner.			
	Applicant may not request that any objection to the	drawing(s) be held in abeyance. S	ee 37 CFR 1.85(a).			
	Replacement drawing sheet(s) including the correction	ion is required if the drawing(s) is o	objected to. See 37 CFR 1.121(d).			
11)[	The oath or declaration is objected to by the Ex	aminer. Note the attached Offic	e Action or form PTO-152.			
Priority (	under 35 U.S.C. § 119	·				
12)	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. & 119/	a)-(d) or (f)			
-	☐ All b)☐ Some * c)⊠ None of:	priority and or or or or or	a) (a) 5. (i).			
ŕ	1.⊠ Certified copies of the priority documents	s have been received.	·			
	2. Certified copies of the priority documents	s have been received in Applica	ation No			
	3. Copies of the certified copies of the prior	ity documents have been recei	ved in this National Stage			
	application from the International Bureau	ı (PCT Rule 17.2(a)).				
* 5	See the attached detailed Office action for a list of	of the certified copies not receive	/ed			
Attachmen	t(s)					
	ee of References Cited (PTO-892)	4) Interview Summa				
3) 🔲 Infon	te of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) or No(s)/Mail Date	Paper No(s)/Mail   5) Notice of Informal 6) Other:	Date Patent Application (PTO-152)			

Application/Control Number: 10/751,390 Page 2

Art Unit: 1763

### **DETAILED ACTION**

### Response to Arguments

1. Applicant's arguments with respect to claims 1 and 3-17 have been considered but are unpersuasive. Namely, applicant argues that the prior art to Rupp et al (US 6,740,167) and Rupp et al (US 2001/0052324) fails to teach the newly amended limitation recited temperature zones. Though neither specifically recites a difference in temperature, the examiner asserts that this temperature variation is inherent. It is further the examiner's position as supported by the specification (page 2 [007]) of the present invention that when a substrate holder comprises two differing zones of electrical conductivity where the zone of higher electrical conductivity is taken up (directly supported by) the substrate and is formed of a metal that zone is ensured to have a hotter temperature than the zone of lower electrical conductivity. It is the materials of construction that drive the temperature variation. Since the materials of the present invention and the prior art are the same. It is inherent that the difference in electrical conduction and temperature is the same. Note, the specification recites metals such as tungsten, tantalum or molybdenum as the materials of construction of the insert and the material of construction of the holder as graphite see page 3 [0007] and [0017] respectively. Rupp et al ('167) teaches a susceptor of graphite, see col. 4 lines 43-59 and inserts of metals tantalum, molybdenum, and tungsten see col.5 liens 10-17. Rupp et al ('324) teaches the susceptor 5 is made of metal carbides over graphite see [0036] and insert 1 made of metals molybdenum or tungsten see [0034]. Note in both prior art reference to Rupp et al the insert (first zone) corresponds to an area supported by the substrate.

Application/Control Number: 10/751,390 Page 3

Art Unit: 1763

# Claim Objections

2. Claims 3 and 5 are objected to because of the following informalities: The term "first" is omitted from zone in the second line of claim 3. Claim 5 should depend from "claim 4" not "claim 1" as it discusses the disk. Appropriate correction is required.

#### Claim Rejections - 35 USC § 102/103

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1,3, 8, 10,11, 14, and 17 –19 are rejected under 35 U.S.C. 102(b) as being anticipated by Rupp et al (US 2001/0052324) or, in the alternative, under 35 U.S.C. 103(a) as obvious over Rupp et al (US 2001/0052324).

Regarding claims 1, 18, and 19: Rupp et al (US 2001/0052324) teaches a device that produces and processes semiconductor substrates. The device inherently be used to deposit particular crystalline layers on an in particular substrate having an HF heated substrate holder (susceptor 1) see Fig.2 wherein the susceptor is heated by HF coils 4 by electrical conduction. The holder holds the substrate with surface to surface contact, the holder has a zone (cutout 6) has a higher electrical conductivity than the SiC coated susceptor 5. Note that the cut-out 6 substantially corresponds (in size and shape) to the supported surface of the substrate. Though,

Art Unit: 1763

Rupp et al does not specifically teach that the materials of construction between the insert and the susceptor differ basis electrical conductivity, it is noted that electrical conductivity is a physical property that is inherent to materials of construction. Rupp et al teaches that the insert 2 (zone 1) is made of a metal while the susceptor is made of coated graphite, see col. 4 lines 43-59 and col. 5 lines 44-52. *The Electrical Conductivity of the Elements Table* provides evidence that graphite (C) has an electrical conductivity of 0 while Ta (0.076), Mo (0.187) and W (0.189) have the recited values in x 10<sup>6</sup> Ohm<sup>-1</sup>cm<sup>-1</sup>. Thus, the insert made of any of these metals (Ta, Mo, or

W) inherently comprises a higher electrical conductivity than graphite (carbon, C). Regarding the temperature zones, though Rupp et al fails to specifically recite a difference in temperature, the examiner asserts that this temperature variation is inherent. It is further the examiner's position as supported by the specification (page 2 [007]) of the present invention that when a substrate holder comprises two differing zones of electrical conductivity where the zone of higher electrical conductivity is taken up (directly supported by) the substrate and is formed of a metal that zone is ensured to have a hotter temperature than the zone of lower electrical conductivity. It is the materials of construction that drive the temperature variation. Since the materials of the present invention and the prior art are the same. It is inherent that the difference in electrical conduction and temperature is the same. Note, the specification recites metals such as tungsten, tantalum or molybdenum as the materials of construction of the insert and the material of construction of the holder as graphite see page 3 [0007] and [0017] respectively.

Regarding claim 3: Section [0034] recites that the susceptor 1 is made of a metal. Note that the non-coated material used to construct the susceptor is the same material of the cut-out while all other portions of the susceptor are coated with covering 5 see [0036].

Regarding claim 8: Section [0034] recites that the insert is made of Mo. Ta, or W.

Page 5

Regarding claim 10: The holder is above the HF coil 4 see Fig. 2

Regarding claim 11: Section [0046] recites that the device of Rupp et al is used in hot wall or cold wall reactors, Fig. 2 illustrates a cold wall reactor wherein heat is distributed to the walls only by the radiation of the heated substrate holder 1.

Regarding claim 14: Rupp et al teaches a holder 1, a HF heater 4, a first holder zone (cut-out 6) and a second substrate holder zone 5 (covering). Metals have a high electrical conductivity relative to non-metals and semiconductors. Note that the cut-out 6 substantially corresponds (in size and shape) to the area taken up by the substrate.

Regarding claim 17: [0034] recites that the insert is made of Mo. Ta, or W.

Regarding claims 18 and 19: Note that the first substrate holder zone having a higher electrical conductivity inherently has an increased amount of energy transferred to the substrate as this corresponds to the definition of electrical conduction being the ease which electric current (a demonstration of energy movement) can pass through a material.

# Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Art Unit: 1763

6. Claims 9 and 12 rejected under 35 U.S.C. 103(a) as being unpatentable over Rupp et al (US 2001/0052324).

The teachings of Rupp et al (US 2001/0052324) were discussed above, specifically the embodiment illustrated and described by Fig. 2.

Page 6

Regarding claim 9: Fig. 2 fails to teach that the holder is surrounded by an HF coil.

Fig. 1 illustrates an embodiment wherein the holder is arranged in a tube wherein trh HF coil surrounds the tube and thus surrounds the holder. The motivation to surround the holder with the HF coil is that the holder can be inductively heater and the holder is heater uniformly on all sides, see [0033] of Rupp et al (US 2001/0052324). Thus, it would have been obvious for one of ordinary skill in the art at the time of the claimed invention to provide HF coil to surround the holder so as to provide uniform heating over all the surfaces of the holder.

Regarding claim 12: Fig.2 fails to teach a tunnel reactor.

Figure 1 of Rupp et al (US 2001/00523324) recites a tunnel (synonymous with tube reactor) reactor according to Section [0033]. The motivation to use a tunnel reactor is that the tubular shape shields the chamber atmosphere of the process gases according to [0033] of Rupp et al US 2001/0052324. Thus, it would have been obvious for one of ordinary skill in the art at the time of the claimed invention to use a tunnel reactor as illustrated in Fig.1 as it shields the chamber atmosphere from the process gases.

7. Claim 1, 8, 10, 11, 14, and 17-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rupp et al ('167) in view of Burk, Jr. et al (US 5,788,777).

Page 7

Art Unit: 1763

Rupp et al (US 6740,167) teaches a device for mounting a substrate. The device includes an insert 2 (zone) made of a metal carbide layer and a susceptor 1 (made of graphite an electrically and thermally conductive material). The wafer is supported in surface to surface contact with the insert such that it substantially corresponds to the supported surface of the substrate.

Regarding claims 1, 18 and 19: Rupp et al '167 fails to teach a heater or how the holder is heated.

Burk, Jr. et al teaches a susceptor 20 wherein rf (a from of HF) coils are provided to heat the holder 20. Col. 2 lines 36-42 recite that the heater 28 is provided to establish the required process temperature of the substrate. Thus, the motivation to provide the susceptor of Rupp et al '167 with the heater 28 is to ensure that the substrate can maintain the required process temperature. Thus, it would have been obvious for one of ordinary skill in the art at the time of the claimed invention to provide the RF coils of Burk, Jr. et al. Regarding the temperature zones, though Rupp et al fails to specifically recite a difference in temperature, the examiner asserts that this temperature variation is inherent. It is further the examiner's position as supported by the specification (page 2 [007]) of the present invention that when a substrate holder comprises two differing zones of electrical conductivity where the zone of higher electrical conductivity is taken up (directly supported by) the substrate and is formed of a metal that zone is ensured to have a hotter temperature than the zone of lower electrical conductivity. It is the materials of construction that drive the temperature variation. Since the materials of the present invention and the prior art are the same. It is inherent that the difference in electrical conduction and temperature is the same. Rupp et al ('167) teaches a susceptor of graphite, see col. 4 lines 43-59

Art Unit: 1763

and inserts of metals tantalum, molybdenum, and tungsten see col.5 liens 10-17. Rupp et al ('324) teaches the susceptor 5 is made of metal carbides over graphite see [0036] and insert 1 made of metals molybdenum or tungsten see [0034]. Note in both prior art reference to Rupp et al the insert (first zone) corresponds to an area supported by the substrate.

Regarding claim 8: The insert piece 2 consist of TaC, MoC, WC according to col. 2 lines 60-64 of Rupp et al '167.

Regarding claim 10: Burk, Jr. et al illustrates that the holder is above the RF coils 28.

Regarding claim 11: The reactor of Burk, Jr. et al is a cold wall reactor, wherein heat is distributed to the walls only by the radiation of the heated substrate holder 20, see Fig.1.

Regarding claim 14: Rupp et al '167 teaches a holder 1, a first holder zone (insert 2) and a second substrate holder zone 1 (susceptor). Metals have a high electrical conductivity relative to non-metals and semiconductors. Note that the insert 2 substantially corresponds (in size and shape) to area taken up by the substrate

Rupp et al '167 fails to a HF heater.

Burk, Jr. et al (US 5,788,777) teaches a susceptor 20 wherein rf (a from of HF) coils are provided to heat the holder 20. Col. 2 lines 36-42 recite that the heater 28 is provided to establish the required process temperature of the substrate. Thus, the motivation to provide the susceptor of Rupp et al '167 with the heater 28 is to ensure that the substrate can maintain the required process temperature. Thus, it would have been obvious for one of ordinary skill in the art at the time of the claimed invention to provide the RF coils of Burk, Jr. et al.

Regarding claim 15: The first zone (insert 2) is formed by a metal carbide (made of a metallica perform) that is insertable into the holder 1, see the abstract.

Regarding claim 16: The insert of Rupp et al ('167) comprises coated graphite, col. 3 lines 3-14.

Regarding claim 17: The insert piece 2 consist of TaC, MoC, WC according to col. 2 lines 60-64 of Rupp et al '167.

Regarding claims 18 and 19: Note that the first substrate holder zone having a higher electrical conductivity inherently has an increased amount of energy transferred to the substrate as this corresponds to the definition of electrical conduction being the ease which electric current (a demonstration of energy movement) can pass through a material.

8. Claims 4-7 and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Burk, Jr. et al (US 5,788,777) in view of Rupp et al '167 or Rupp et al (US 2001/00523324).

Burk, Jr. et al teaches a susceptor 20 wherein rf (a from of HF) coils are provided to heat the holder 20. Col. 2 lines 36-42 recite that the heater 28 is provided to establish the required process temperature of the substrate, see Figs. 1, 4,5, 7, 7A, and &B..

Regarding claim 4: Burk, Jr. et al teaches that the holder 20/86 has a plurality of substrate bearing disks which are mounted on a gas bearing and each having an insert piece 22/90.

Regarding claim 5: The disks 86 consist of metal, specifically graphite according to col. 4 lines 10-25 of Burk, Jr. et al.

Regarding claim 6: Figs. 4 and 5 illustrate that the disks are disposed in a planetary fashion.

Art Unit: 1763

Regarding claim 7: Located in substrate bearing disk is located a gas bearing in a bearing recess, see Figs. 1. 7, 7A, and 7B.

Regarding claim 13: Gas enters the reactor via pipe 36,92 according to col. 4 lines 10-25.

Burk, Jr. et al fails to teach the insert piece has zone of higher electrical conductivity nor that the insert is made of metal.

Rupp et al '167 teaches a wafer supported by a susceptor 1 that includes an insert 2 wherein the wafer is in surface to surface contact with the insert. Rupp et al '167 teaches in col. 2 lines 49-64 the advantage of incorporating a high temperature region (zone) in the susceptor with the motivation that such zones ensure that no contamination from the susceptor will diffuse into the substrate. Thus, it would have been obvious to construct the susceptor of Burk, Jr. et al wherein the area 22 that is in surface to surface contact with the wafer is made of a material of higher electrical conductivity such as a metal carbide.

Likewise, Rupp et al (US 2001/0052324) teaches a holder that holds the substrate with surface to surface contact, the holder has a zone (cutout 6) has a higher electrical conductivity that the SiC coated susceptor 5. Note that the cut-out 6 substantially corresponds (in size and shape) to the supported surface of the substrate. The abstract teaches that the motivation to construct the device of Rupp et al in this fashion so to ensure that no contamination of the substrate during the production process. Thus, it would have been obvious to construct the susceptor of Burk et al wherein the area 6 (cut-out) that is in surface to surface contact with the substrate is made of a different material that the other portions of the susceptor. Though, Rupp et al does not specifically teach that the difference in the material of construction between the covering 5 and the susceptor cutout 6 is basis electrical conductivity it is noted that Ta, W, and

Art Unit: 1763

Mo are materials with a higher electrical conductivity than (graphite, C or silicon, Si) as evidenced by *The Electrical Conductivity of the Elements Table*. Thus, it would have been obvious to construct the susceptor of Burk, Jr. et al wherein the area 22 that is in surface to surface contact with the wafer is made of a material of higher electrical conductivity such as a metal carbide.

Page 11

#### Conclusion

9. Applicant's amendment (recitation of the temperature zones) necessitated the new ground(s) of rejection (using 102/103) presented in this Office action. Accordingly, **THIS**ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sylvia R. MacArthur whose telephone number is 571-272-1438. The examiner can normally be reached on M-Th during the hours of 8 a.m. and 4:30 p.m.

Application/Control Number: 10/751,390 Page 12

Art Unit: 1763

11. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197/(toll-free).

Primary Examiner
Art Unit 1763

June 1, 2007